IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of : Docket No. 0074-537949

Simon Anthony Brown et al. : Confirmation No. 4961

U.S. Appln. No. 10/573,123 :

1 11/12/2007

Filed: 11/13/2006 :

For: Etch Masks Based on Template-Assembled:
Nanoclusters:

INFORMATION DISCLOSURE STATEMENT

In compliance with the Duty of Disclosure set forth in 37 C.F.R. §1.56, Applicants are submitting herewith Forms PTO/SB/08A and 08B with this statement.

Please note that this application is the U.S. national phase of International Patent Application No. PCT/NZ2004/000230, filed September 23, 2004. An International Search Report was established for this international application and was published with the international application on March 31, 2005. A copy of the International Search Report and the references cited therein were received by the U.S. Patent and Trademark Office as indicated on Form PTO/DO/EO/903 mailed on November 29, 2006. The references cited in the International Search Report of the international application are listed on the Forms PTO/SB/08A and 08B, but are not enclosed herewith so that they can be printed on the face of the patent when it issues.

This submission is being made in accordance with 37 C.F.R. §1.97 and is believed to be in full compliance with the requirements of 37 C.F.R. §1.98.

Applicants respectfully request full and proper consideration of the listed information

In re the Application of Simon Anthony Brown et al. Application No. 10/573,123 Docket No. 0074-537949

during examination of the application, and that the listed information be printed on any patent which issues therefrom.

Respectfully submitted,

DANN, DORFMAN, HERRELL AND SKILLMAN

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Enclosure: Form PTO/SB/08A and 08B

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				Complete if Known		
Substitute for form 1449/PTO				Application Number	10/573,123	
INF	ORMATION	DIS	CLOSURE	Filing Date	11/13/2006	
STA	TEMENT E	BY A	PPLICANT	First Named Inventor	Simon Anthony Brown	
				Art Unit	n/a	
(Use as many sheets as necessary)				Examiner Name	n/a	
Sheet	1	of	2	Attorney Docket Number	0074-537949	

		NON PATENT LITERATURE DOCUMENTS			
Examiner Initials*	er Cite Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title				
		S.M. SZE, "Semiconductor Devices - Physics and Technology," pp. 428-451, Wiley, New York, 1985			
		T. HAATAINEN et al., "Pattern Transfer using Step&Stamp Imprint Lithography," Physica Scripta, 2003			
		M. COLBURN et al., "Step and Flash Imprint Lithography: A New Approach to High-Resolution Patterning," Proc. SPIE, Vol. 3676, 1999			
	D-Y KHANG et al., "Room-temperature imprint lithography by solvent vapor treatment," Appl. Phys. Letters, Vol. 76, No. 7, 2000				
		M. LI et al., "Direct three-dimensional patterning using nanoimprint lithography," Appl. Phys. Letters, Vol 78, No. 21, 2001			
		G.M. FRANCIS et al., "Diffusion controlled growth of metallic nanoclusters at selected surface sites," J. Appl. Phys., Vol. 79, No. 6, 1996			
		W.A. DE HEER, "The physics of simple metal clusters: experimental aspects and simple models," Rev. of Mod. Phys., Vol. 65, No. 3, 1993			
		I.M. GOLDBY et al., "Diffusion and aggregation of size-selected silver clusters on a graphite surface," Appl. Phys. Lett., Vol. 69, No. 19, 1996			
		S.J. TANS et al., "Room-temperature transistor based on a single carbon nanotube," Nature, Vol. 393, 1998			
		H.D. CHOPRA et al., "Ballistic magnetoresistance over 3000% in Ni nanocontacts at room temperature," Phys. Rev., Vol. B 66, 2002			

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Substitute for form 1449/PTO				Complete if Known		
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INFO	ORMATION	DIS	CLOSURE	Filing Date	11/13/2006	
STA	TEMENT E	BY A	PPLICANT	First Named Inventor	Simon Anthony Brown	
				Art Unit	n/a	
	(Use as many she	ets as n	ecessary)	Examiner Name	n/a	
Sheet	2	of	2	Attorney Docket Number	0074-537949	
Sheet	2	of	2	Attorney Booker Hamber	0074-537949	

		NON PATENT LITERATURE DOCUMENTS			
Examiner Initials*	Cite No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ²		
		C.Z. LI et al., "Molecular detection based on conductance quantization of nanowires," Appl. Phys. Letters, Vol. 76, No. 10, 2000			
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		B. HALL, "An installation for the study of unsupported ultrafine particles by electron diffraction, with application to silver: observation of multiply twinned particle			
		structures," Ecole Polytechnique Federale de Lausanne, Switzerland, 1991			
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		T. MULLER et al., "Template-directed self-assembly of buried nanowires and the pearling of instability," Mat. Sci. and Eng., C 19, 2002			
		J.G. PARTRIDGE et al., "Templated cluster assembly for production of metallic nanowires in passivated silicon V-grooves," Micro. Eng., 2004			
		T. TADA et al., "Channel waveguides fabricated in 2D photonic crystals of Si nanopillars," Micro. Eng., 2002			

Examiner	Date	
Signature	Considered	

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Complete if Known Substitute for form 1449/PTO 10/573,123 Application Number Filing Date 11/13/2006 INFORMATION DISCLOSURE First Named Inventor Simon Anthony Brown STATEMENT BY APPLICANT Art Unit n/a (Use as many sheets as necessary) n/a **Examiner Name** 0074-537949

Sheet 1

Attorney Docket Number

				DOCUMENTS	Dance Columns Lines Mises
Examiner Initials*	Cite No.1	Document Number Number-Kind Code ^{2 (f known)}	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
	<u> </u>	US- 6579463	06/17/2003	Winningham et al.	
		^{US-} 6413880	07/02/2002	Baski et al.	
		^{US-} 6773616	08/10/2004	Chen et al.	
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		FOREIG	GN PATENT DOCU	JMENTS		
Examiner Initials*	Cite No.1	Foreign Patent Document	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages Or Relevant Figures Appear	T ⁶
	ļ	Country Code ³ Number ⁴ Kind Code ⁵ (if known)	WWW. DB TTTT			<u> </u>
		WO 2004/069735	08/19/2004	Nanocluster Devices Ltd.		<u> </u>
		PCT/NZ02/00160	02/27/2003	Canterprise Limited		_
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